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Semiconductor Materials And Process Technology Handbook (VLSI And ULSI)



Synopsis

This handbook is a broad review of semiconductor materials and process technology, with emphasis on very large-scale integration (VLSI) and ultra large scale integration (ULSI). The technology of integrated circuit (IC) processing is expanding so rapidly that it can be difficult for the scientist working in one area to keep abreast of developments in other areas of the field. This handbook solves this problem by bringing together "snapshots" of the various aspects of the technology.

Book Information

Hardcover: 688 pages

Publisher: Noyes Publications; 1 edition (January 14, 1989)

Language: English

ISBN-10: 0815511507

ISBN-13: 978-0815511502

Product Dimensions: 7 x 1.4 x 10 inches

Shipping Weight: 2.6 pounds (View shipping rates and policies)

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